



AF 2813
ITW

PATENT
Customer No. 22,852
Attorney Docket No. 08244.0032

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Sung-Chan PARK et al.) Group Art Unit: 2813
)
Application No.: 09/998,303) Examiner: Nguyen, Thanh T.
)
Filed: December 3, 2001)
)
For: METHOD FOR FORMING)
CONTACT HOLE AND SPACER)
OF SEMICONDUCTOR DEVICE)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Entered
w/RCE
9/20/04
C.Pei

AMENDMENT UNDER 37 C.F.R. § 1.116

In reply to the Final Office Action mailed on May 10, 2004, the period for response to which extends through August 10, 2004, Applicants propose to amend this application as follows and respectfully request reconsideration in view of the following remarks.

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks follow the Amendments to the Claims and begin on page 4 of this paper.